

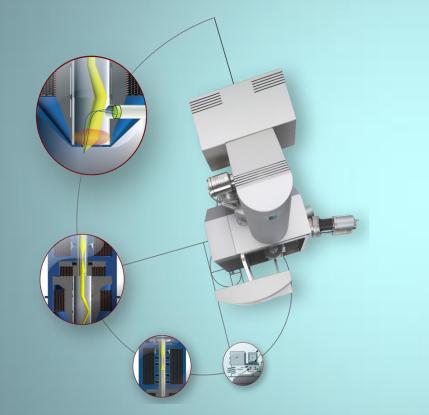
TESCAN MIRA FESEM Presentation

Global Supplier of Scanning Electron Microscopes

TESCAN USA 508 Thomson Park Drive Cranberry TWP, PA 16066



Outline



About TESCAN

- **Product Portfolio**
- **MIRA FESEM Overview**
 - Electron Optics
 - Various Models
 - Features

- **EDS Analysis**
 - **Imaging Results**

Value & Excellence in SEMs

8





Established: 1991 Location: Brno, Czech Republic Field of Activity:

Research, development, manufacturing and worldwide supply of scanning electron microscopes and related products



Main Products:

- Scanning electron microscopes
- High resolution Schottky FE-SEMs
- Focused ion beam SEMs
 - Detectors and accessories for SEMs
 - Nanotechnology Instrumentation

Value & Excellence in SEMs

8



TESCAN Product Line 2012



About TESCAN





Fig. Brno International Trade Fair Center



Fig. First Czechoslovak electron microscope Tesla BS241 (1951), Tesla BS242 (1954)

Historical Background

Brno, Czech Republic

- The second largest city in the Czech Republic
- Traditional center of industry and commerce and Central European trade fairs
- 6 Universities with 27 faculties and about 80,000 students
- Origin of world-famous researchers
- 15 Institutes of Academy of Science

Electron Microscopy in Brno

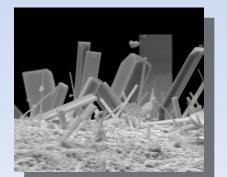
- Over 60 years tradition of electron microscopy in Brno
- Former leading supplier of EM for Eastern Europe
- Location of other SEM manufacturers



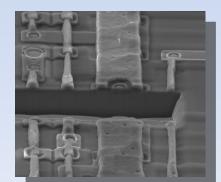


Historical Facts

- The first TEM assembled at the Technical University of Brno at the end of the 1940's
- TESLA Brno introduced the first commercial TEM in 1953
 - the leading manufacturer of Electron-Optical Devices in Eastern Europe in the 2nd half of the 20th century
- The Institute of Scientific Instruments of the Academy of Science of the Czech Republic was founded in 1956
- The Tesla BS-242 TEM was awarded the gold medal at the World Exhibition in Brussels in 1958
- Tesla Brno manufactured over 4,000 devices (TEM + SEM) during four decades of its existence
- TESCAN founded by former engineers and managers of Tesla Brno (Jaroslav Klima, former head of Tesla's SEM Division)
- TESCAN, a.s. is one of the companies successfully continuing the electron microscopy tradition in Brno









From R&D to a Final Product



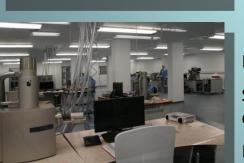
TESCAN Team: more than 160 employees



TESCAN today







TESCAN are total about 4500 m² 480 m² Mechanical Workshops 265 m² **Electrical Workshops** 200 m² Assembling 160 m² **Stores** 350 m² Final Assembling (clean rooms) 300 m² Packaging 70 m² **Clean R&D** laboratiories **Demonstration laboratiories** Standard 30 m² Clean 40 m² **R&D** offices 150 m² Sales, logistics, economics and 680 m² company management offices 395 m² Meeting rooms







TESCAN Future and Strengths





TESCAN, a.s. 20 Years of Tradition and Excellence in Scanning Electron Microscopy

- New premises
- Modern manufacturing facilities
- Strong research and development
- Clean rooms for assembling
- Educated and experienced team
- Worldwide sales and service network







MIRA3



North America Headquarters Location: Cranberry Township, PA (Pittsburgh, PA)



West Coast Demonstration Lab Location: Pleasanton, California



International References





TESCAN USA CUSTOMERS





Jacksonville









Orlando TESCAN provides a guaranteed 48 hour response time (Our Goal is 24 hours) & guaranteed 95% uptime.









TESCAN USA CUSTOMERS









US Steel PPG Industries



TESCAN provides a guaranteed 48 hour response time (Our Goal is 24 hours) & guaranteed 95% uptime.





MIRA3



Specific Features

- High resolution Schottky FEG-SEM
- Unique Wide Field Optics SEM optics design
- Intermediate lens (IML) for the beam aperture optimization
- Uniform energy
- In-Flight Beam Tracing[™]
- Stereoscopic imaging 3D Beam Technology
- UniVac variable pressure version
- Beam Deceleration
- Large Chamber and Stage Capability
- Variable Pressure

Optional / Accessories / Software modules

- On axis In-Column SE and BSE Detector for high resolution at lower kV
- STEM Detector
- Low Vacuum Secondary TESCAN Detector (LVSTD)
- 16k x 16k Image Store as standard
- Beam Blanker
- Load Lock
- Peltier Cooling Stage
- Nanomanipulators, etc.



SEM Column





High Resolution Schottky FEG SEM

- Point source high brightness Schottky emitter
- Convergent beam, uniform energy, minimized aberrations

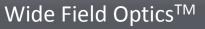
Wide Field Optics™

- Unique Tescan three-lens column design optimized for FE source
- IML Intermediate lens for beam aperture optimization
- Automated alignment

In-Flight Beam Tracing™

Original control of the beam properties









Tescan SEMs = World's Largest Magnification Range

From Centimeters...

- Unique Wide Field Mode (in centimeters)
- Extra-low magnification (down to 1,2x)
- Extra wide scanning angle (up to 45°)

...to Nanometers

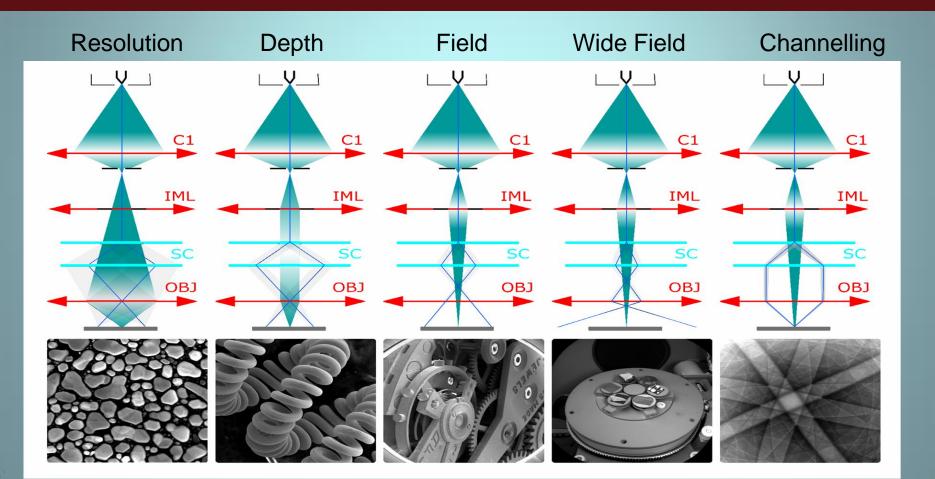
High Resolution Shottky FE-SEM (1.2 nm)

F*ig***M**agnification up to 1,000,000x Top: Defining areas for automated analysis Bottom: High resolution test





Wide Field Optics™ Range of Scanning Modes





Principles of the beam deceleration

MIRA3

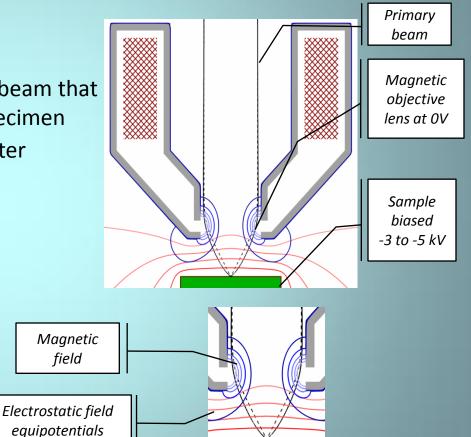
Principles of the beam deceleration:

- Applying negative voltage on the specimen
- Using higher accelerating voltage of primary beam that is decelerated just before its landing on the specimen
- Results in smaller chromatic aberration = better resolution

Example:

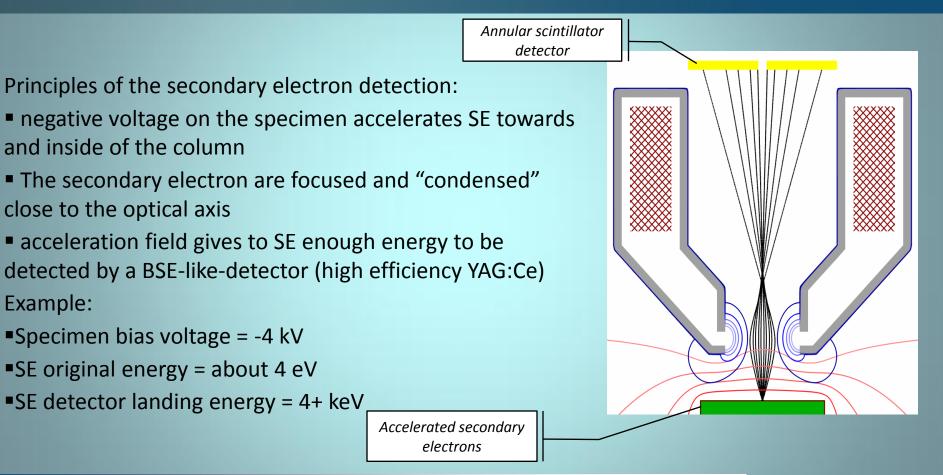
- Primary beam energy = 5 keV
- Specimen bias voltage = -4 kV
- ■Landing energy = 5 4 = 1 keV

Special feature: In-Flight Beam Tracing[™] controls precise focus in DM





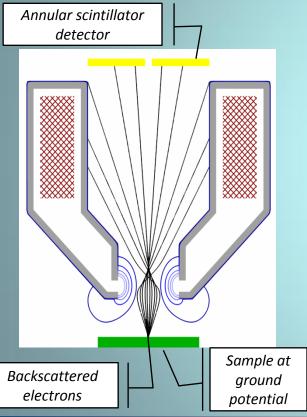
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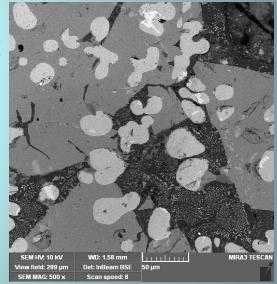
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In-beam BSE detector

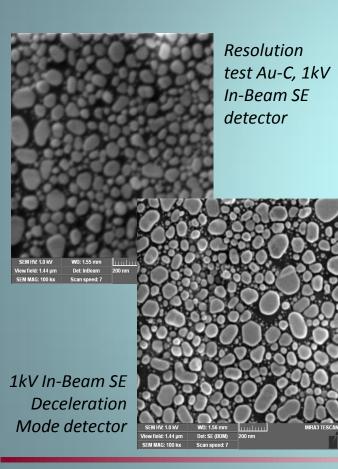


- Sample at the ground potential
- High angle back-scattered electrons detected by in-beam detector (same detector as for the deceleration mode)
- Complementary signal to the standard (below pole piece) BSE detector that detects rather low angle back-scattered electrons
- Enables to use very short WD
- Frees space under objective lens for other detectors



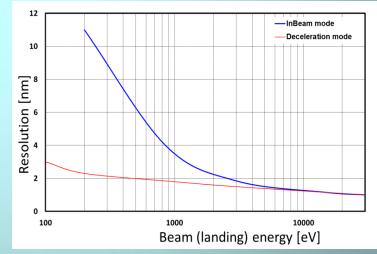
Blast Furnace Slug (FE/Si/Al/Zr)





Advantages of the beam deceleration mode:

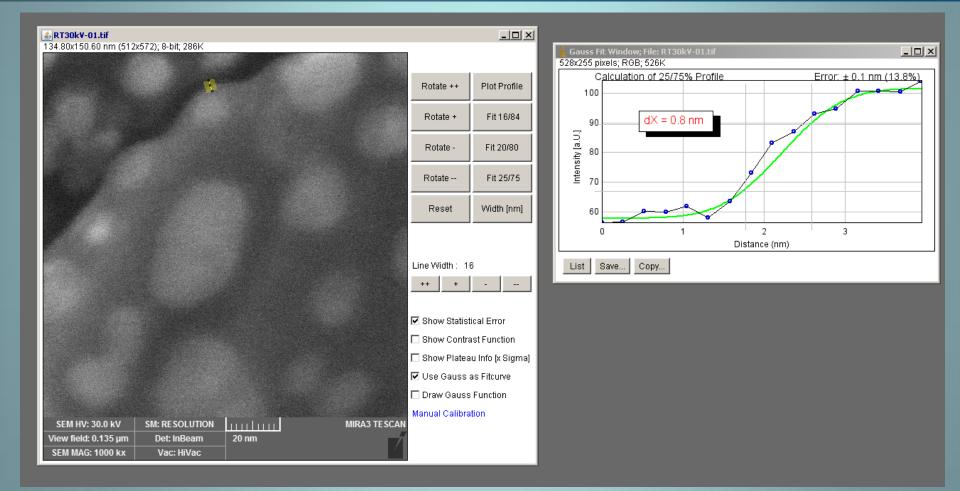
- achieving very low landing voltages down to 100 V
- reduced beam damage of sensitive samples
- much better resolution at low and ultra-low voltages
 1.5 nm @ 3 kV < 2.0 nm @ 1 kV 2.5 nm @ 200 V



Value & Excellence in FIB-SEMs

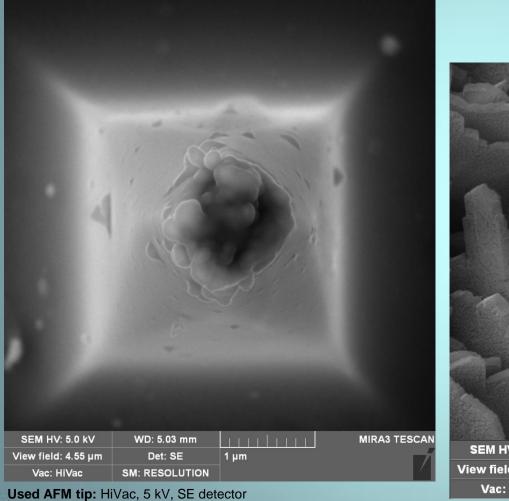


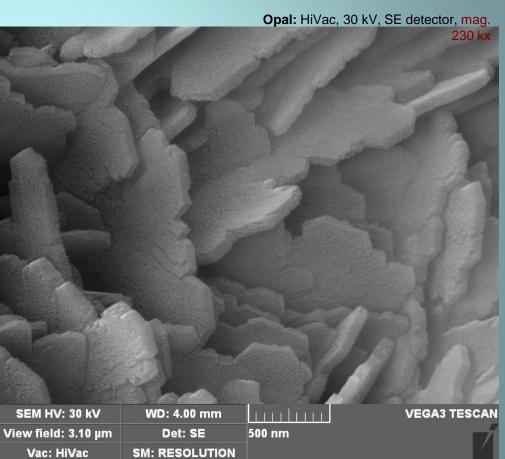
Resolution Test



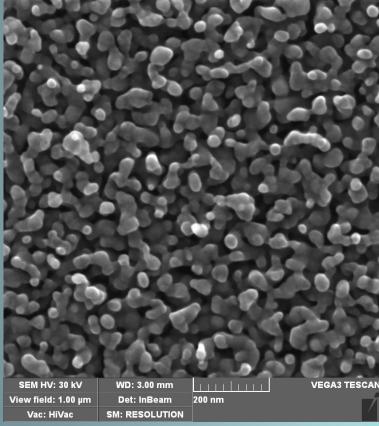












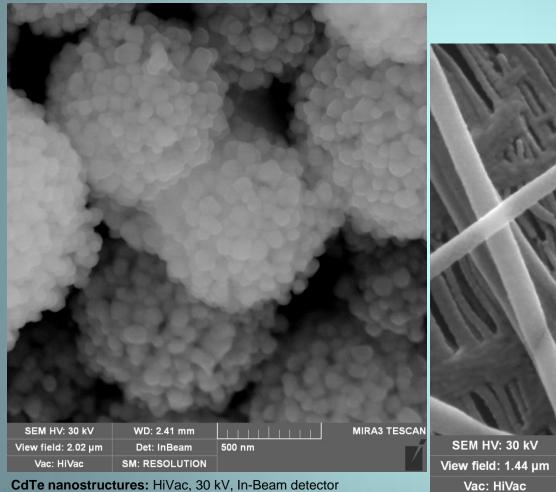
Ag nanoclusters: HiVac, 30 kV, In-Beam detector, mag. 217

- Special detector position (in lens)
- Detects SE which are emitted back into the objective
- Allows specimen examination at very short working distance
- Outstanding resolution (1 nm at 30 kV, 2 nm at 3 kV)
- Available only for MIRA3 FEG-SEM





MIRA3 TESCAN



Nanofibers (gold coated): HiVac, 30 kV, In-Beam detector, mag. 300 kx

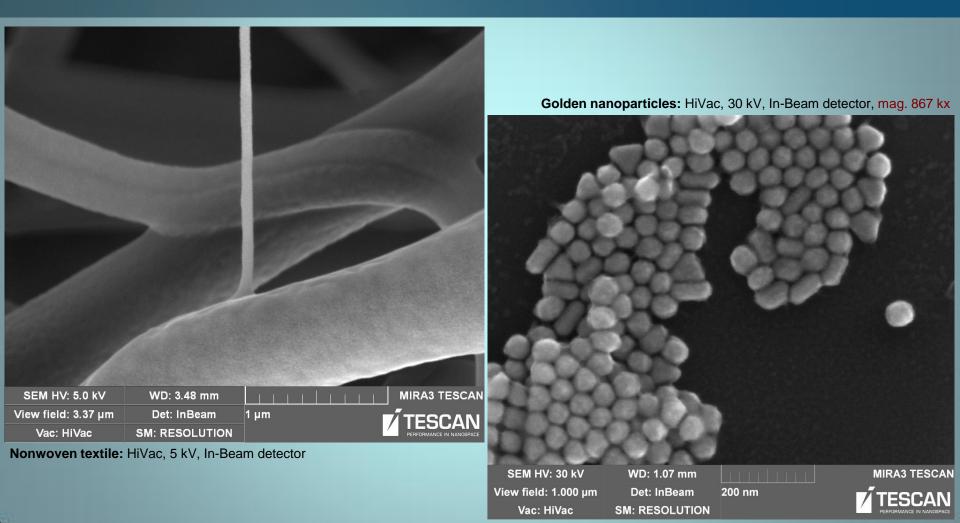
WD: 2.22 mm

Det: InBeam

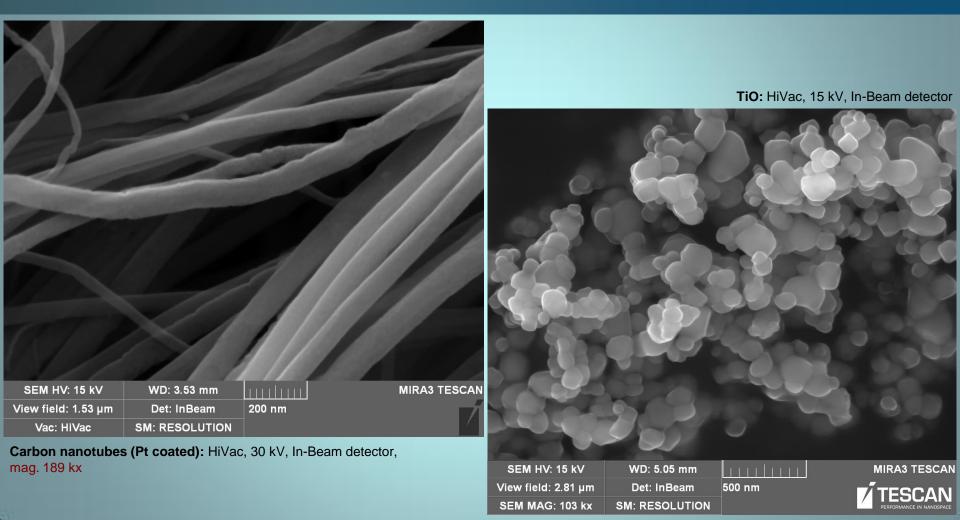
SM: RESOLUTION

200 nm



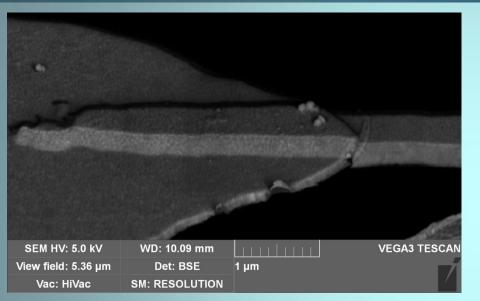






BSE Detector





YAG scintillator detector

Equipped with first-class single-crystal YAG scintillator

■High efficiency – low noise

Fast imaging rate

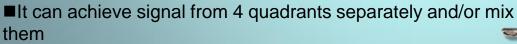
■High resolution (2 nm at 30 kV)

High sensitivity and atomic number resolution (0.1 Z)

Retractable (manual/motorized) version

Semiconductor with metalic bridge: HiVac, 5 kV, BSE detector

4-Quadrant semiconductor detector



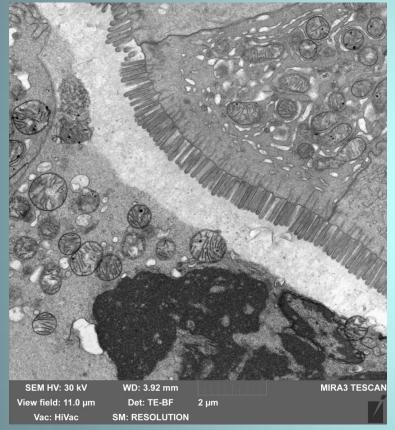
Used to get both compositional and topographical contrast







STEM Detector



Cross section of the rat intestine: HiVac, 30 kV, STEM detector (bright field)

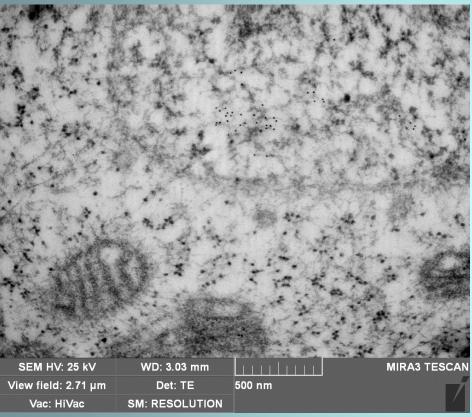
Value & Excellence in SEMs

- Ultrastructure of samples observed in SEM
- Suitable for life science, material science, nanotechnology, etc.
- High magnification
- High resolution (0,8 nm at 30 kV)
- Sample preparation techniques same as for TEM
- Good contrast of images achieved without staining
- Simultaneous dark field and bright field imaging



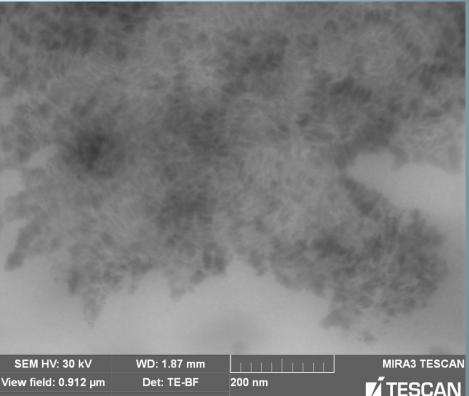


STEM Detector



Immunolabeling (10 nm gold nanoparticles): HiVac, 25 kV, STEM detector (bright field)

Ash: HiVac, 30 kV, STEM detector (bright field), mag. 396 kx

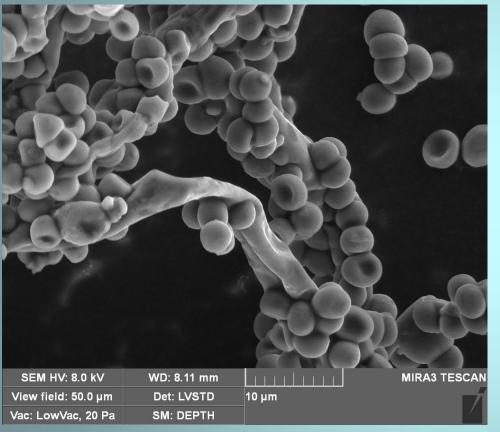


SM: RESOLUTION

Vac: HiVac



LVSTD Low Vacuum Secondary TESCAN Detector



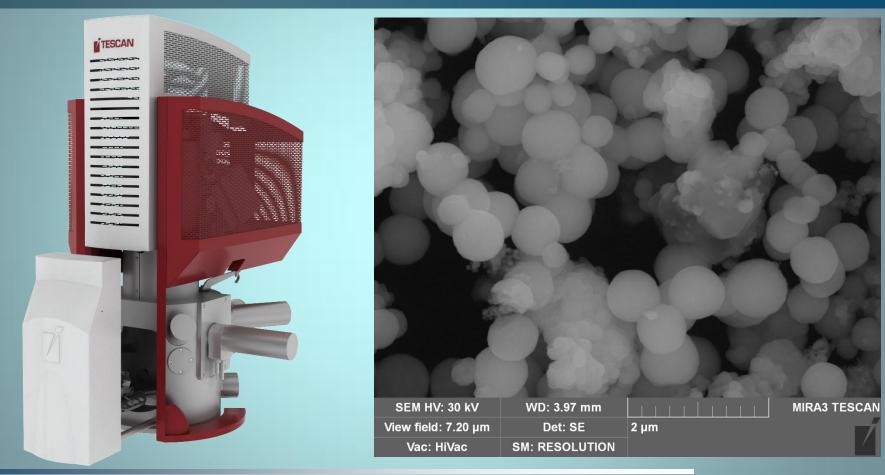
Blue- green mold (*Penicillium Roqueforti*): UniVac, 20 Pa, Water Vapor, -36°C, 20 kV, LVSTD Value & Excellence in SEMs

Original design

- Convenient for non-conductive samples investigation
- Modified Everhart-Thornley design
 patented by TESCAN
- True secondary electron detecting in low vacuum condition
- Microlens differential barrier





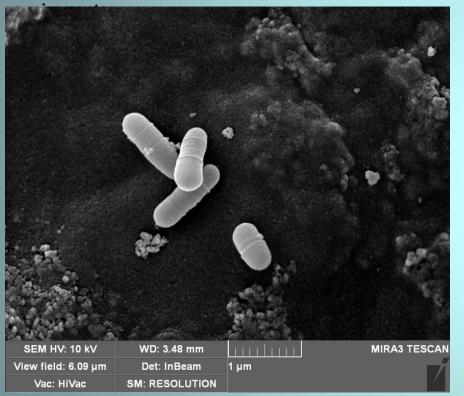


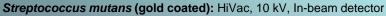
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CdTe nanostructures: HiVac, 30 kV, SE detector



Please contact us if you have any questions about analyses or further







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